

Electronic Patent Application Fee Transmittal

Application Number:	10528069			
Filing Date:	10-Jul-2006			
Title of Invention:	Thermal Treatment Apparatus, Method For Manufacturing Semiconductor Device, And Method For Manufacturing Substrate			
First Named Inventor/Applicant Name:	Naoto Nakamura			
Filer:	James Albert Oliff/April D'Andrea			
Attorney Docket Number:	122733			
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U.S. National Stage under 35 USC 371 Filing Fees				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
Post-Allowance-and-Post-Issuance:				
Extension-of-Time:				

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Submission- Information Disclosure Stmt	1806	1	180	180
Total in USD (\$)				180